

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

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Confirmation No. 9277

Application No. 10/609,339

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For: **DIAPHRAGM VALVE WITH
RELIABILITY ENHANCEMENTS
FOR ATOMIC LAYER DEPOSITION**

Group Art Unit: 3753

Examiner: Kevin L. Lee

Date: July 11, 2005

AMENDMENT

TO THE COMMISSIONER FOR PATENTS:

In response to the March 9, 2005 Office action, please amend the above-identified patent application as follows.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims that begins on page 3 of this paper.

Remarks begin on page 12 of this paper.

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01 FC:2202	650.00 OP
02 FC:2201	500.00 OP